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Schematic representation
of a vacuum system.

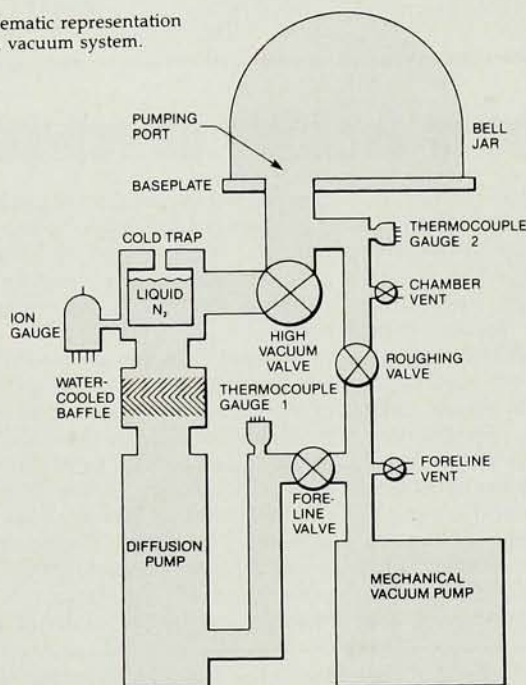


Illustration reprinted from R.V. Stuart, *Vacuum Technology, Thin Films, and Sputtering* (Orlando, Academic Press, Inc., 1983), page 43; figure 5.



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c. 358 pp. in preparation
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R. V. STUART

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